

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	25913	(mark\$3 or indentify\$3) near10 (substrate or wafer)	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/09/12 15:27
L2	31548	(mark\$3 or identify\$3) near10 (substrate or wafer)	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/09/12 15:27
L3	8476	2 and laser	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/09/12 15:28
L4	3578	2 and laser near2 beam	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/09/12 15:28
L5	752	4 and (identification or ID)	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/09/12 15:28